## Influence of thermal treatment-induced atomic states on spin orbit torque in MgO/CoFeB/W stacks

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## 1. INTRODUCTION

Spin-orbit-torque (SOT) effect, which arises from in-plane current, has recently garnered considerable attention as a novel magnetization switching mechanism forlow power consumption, and new physical phenomenon [1,2]. The Rashba effect and the spin Hall effect have been considered to generate this kind of magnetic switching operated by SOT [3]. However, X. Qiu [4] has reported that there may be a new mechanism of spin-orbit torque associated with the oxidation states. Therefore, we examined the current-induced effective field related with SOT in W/CoFeB/MgO stacks with various post-annealing temperatures. SOT property has been investigated as atomic states and distribution at various annealing temperatures are changed.

## 2. EXPERIMENTAL DETAILS

MgO/Co<sub>20</sub>Fe<sub>60</sub>B<sub>20</sub>/W stacks were prepared on thermally oxidized Si substrates utilizing a radio-frequency (RF) magnetron sputtering-system. Species were [Si/SiO<sub>2</sub>] Substrate/MgO (2)/Co<sub>20</sub>Fe<sub>60</sub>B<sub>20</sub> (t<sub>CFB</sub>)/W (8), where numbers in parenthesis refer to layer thickness in nanometers. To show post-annealing influence on magnetic and atomic features, a post-annealing process was carried out at 325°C, 350°C, 375°C, and 400°C for 1 hour under vacuum conditions below ~1 x 10<sup>-6</sup> Torr, with a 3T perpendicular magnetic field. Finally, these stacks were patterned into the width and length with 20  $\mu$ m and 120  $\mu$ m Hall bar by standard photolithography and Ar ion-milling techniques.

## References

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